Special Issue

Process Modelling and Simulation

Message from the Guest Editors

This Special issue of *Processes*, dedicated to "Process Modelling and Simulation", aims to collect novel developments in the field in order to address the challenges brought by the use of models in its different facets, and to reflect the state of the art in methods, tools and applications. Topics include, but are not limited to:

- Modelling methodologies
- Model development
- Model online adaptation
- Parameter estimation
- Process-model uncertainty quantification
- Simulation environments
- Grey-box models
- Hybrid modelling
- Multiscale systems
- Numerical methods
- Distributed modelsModel reduction
- Data driven models
- Applications illustrating recent advances and/or outstanding research gaps in the above areas

Guest Editors

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Deadline for manuscript submissions

closed (28 February 2019)



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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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